

Title (en)
PROCESS FOR ASHING ORGANIC MATERIALS FROM SUBSTRATES

Title (de)
VERFAHREN ZUR VERASCHUNG VON ORGANISCHEN MATERIALEN AUF SUBSTRATEN

Title (fr)
PROCEDE DE BRULAGE DE MATERIAUX ORGANIQUES PRESENTS A LA SURFACE DE SUBSTRATS

Publication
EP 1074043 A1 20010207 (EN)

Application
EP 99904261 A 19990126

Priority
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• US 1469598 A 19980128

Abstract (en)
[origin: WO9939382A1] Ashing of an organic film from a substrate is carried out by providing a plasma comprising a gas or gas mixture selected from the following groups: (a) sulfur trioxide alone; (2) sulfur trioxide plus one supplemental gas; and (3) sulfur trioxide plus at least two supplemental gases. Any of the following gases may be employed as the supplemental gas: water vapor, ozone, hydrogen, nitrogen, nitrogen oxides, or a halogenide such as tetrafluoromethane, chlorine, nitrogen trifluoride, hexafluoroethane, or methyltrifluoride.

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H01L 21/302; C09K 13/00

IPC 8 full level
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